



op 1752 - JFW

PATENT
30205/38083

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Geun Su Lee et al.

Serial No.: 10/054,532

Filed: January 22, 2002

For: Photoresist Monomers, Polymers
Thereof and Photoresist Compositions
Containing the Same

Group Art Unit: 1752

Examiner: Yvette C. Thornton

) I hereby certify that this paper and the
) documents referred to as enclosed
) therewith are being deposited with the
) United States Postal Service as first class
) mail, postage prepaid, on **November 15,**
) **2004**, in an envelope addressed to MS
) Amendment, Commissioner for Patents,
) P.O. Box 1450, Alexandria, Virginia
) 22313-1450

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AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Dear Commissioner:

Please enter the following amendment in response to the office action mailed on August 23, 2004.

A listing of the claims and a complete listing of the claims begins on page 2 of this paper.

Remarks/Arguments begin on page 9 of this paper.